

Form PTO-1449

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APPLICATION NO.
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INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(Use several sheets if necessary)

APPLICANT
PARK et al.

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1997 U.S. PTO
09/998131
12/03/01

U.S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

[illegible]

OTHER DOCUMENTS (Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.

Van Den Hove, A Self-Aligned CoSi₂ Interconnection and Contact Technology, IEEE Trans On Electron Device, pp. 554-561, 3/1997

Broadbent et al., Application Of Self-Aligned CoSi₂ interconnection in Submicrometer CMOS Transistors, IEEE Transaction On Electron Devices, pp 2440-2446, 11/1989

EXAMINER

DATE CONSIDERED

08/09/02

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